





## RECOMMENDED PROCESS APPLICATIONS

- Wet etch (oxide, nitride, metal)
- Wet photoresist strip (acid, solvent)
- Wet cleaning (batch and single wafer)
- Photolithography track pre-cleaning
- Electrochemical Plating

Statements and recommendations in this publication are based on our experience and knowledge of typical applications of this product and shall not constitute a guarantee of performance nor modify or alter our standard warranty applicable to such products.

Prior to actual use it is recommended compatibility tests be run to determine suitability in a specific application. This is critical where failure could result in injury or damage. A regular program of inspection and replacement should be implemented. Greene, Tweed technical personnel are available to help with a recommendation.



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